

**TAGA HONORS AWARD 1986**

to

**JOHN MAC PHEE**

*for his work in the development of new press accessories and investigations of the lithographic process which have led to ten inventions and over 50 patents in the U.S. and abroad; for his technical contributions to TAGA meetings; and for his dedicated services to TAGA, GATF, and PIA Web Offset Section, TAGA honors John MacPhee.*



**JOHN MAC PHEE** has been engaged in graphic arts research and development since 1972, when he joined Baldwin Technology Corporation as Vice President, Engineering. He had spent 20 years in nuclear energy development, designing research and power reactors, in metal working and in the development of industrial robots. In 1981 he was promoted to his current corporate position of Vice President, Research and Technology.

John received a BEE degree from Rensselaer Polytechnic Institute in 1952. In 1954 he completed a one-year nuclear engineering program at the Oak Ridge School of Reactor Technical and in 1983 he received an MS degree in Business Policy from Columbia University. He is a licensed professional engineer and a member of three honor societies: Tau Beta Pi (engineering), Eta Kappa Nu (electrical engineering), and Beta Gamma Sigma (business).

John MacPhee has been a member of TAGA since 1975, was president in 1984, and is very active on the Ink and Paper Committee. He is presently Chairman of the GATF Research Committee and a member of the Suppliers Advisory Board of the Web Offset Section of PIA.

John's research in the graphic arts industry has involved him in the development of new press accessories and in studies which have led to an improved understanding of the lithographic process primarily in the area of ink-water balance. These studies have resulted in ten inventions which have been subjects of over 50 patents worldwide and of a number of papers presented by him at annual TAGA meetings.